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Thermoelectric properties of higher manganese silicide films deposited by radio frequency magnetron co-sputtering

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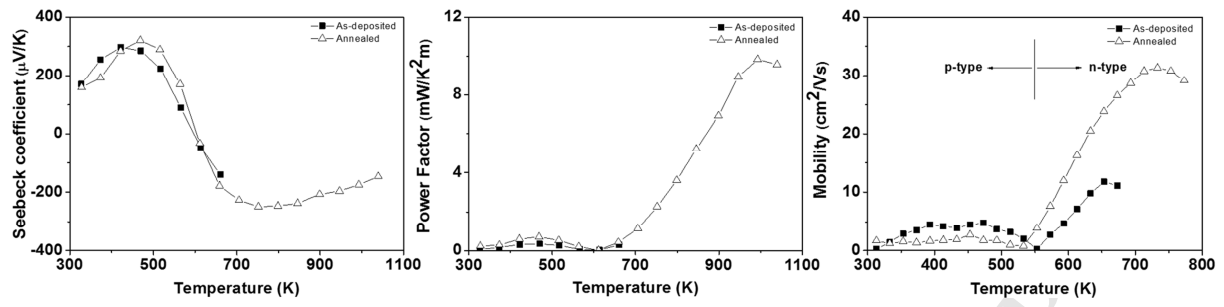
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